

REMARKS

Claim 1 has been cancelled, without prejudice or disclaimer, in favor of newly presented Claims 2-11.

Claims 2-11 are based on allowed Claims 21-30 of the parent application. Claim 2 differs from parent Claim 21 in that it does not specifically recite that the thermal CVD reactor is a cold-wall reactor, but instead recites that the reactor is operated under cold-wall thermal CVD conditions and that the silicon nitride film is deposited by cold-wall thermal CVD.

The rejection of Claim 1 is, of course, moot in view of the cancellation of that claim. Moreover, the patentability of the newly presented claims over the cited Ohta and Egawa patents is evident from the discussion of these patents in relation to parent Claim 21 in the parent application.

Accordingly, early and favorable action with respect to the newly presented claims is respectfully requested.

The Commissioner is hereby authorized to charge to Deposit Account No. 50-1165 any fees under 37 C.F.R. §§ 1.16 and 1.17 that may be required by this paper and to credit any overpayment to that Account. If any extension of time is required in connection with the filing of this

paper and has not been requested separately, such extension
is hereby requested.

Respectfully submitted,

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